

IN THE CLAIMS:

Please amend claim 1 as follows:

1. (Currently Amended) A polycrystalline structure film comprising:
spatially spaced metallic nucleation sites formed on a surface of a substrate,
said metallic nucleation sites including a compound; and
a metallic crystal layer covering over the surface of the substrate and containing
crystal grains having grown from the metallic nucleation sites, each of the crystal grains
containing one of the metallic nucleation sites inside.
2. (Original) The polycrystalline structure film according to claim 1,
wherein said compound is a metallic compound.
3. (Original) The polycrystalline structure film according to claim 2,
wherein said metallic compound includes at least one of a metallic nitride and a metallic
oxide.
4. (Original) The polycrystalline structure film according to claim 3,
wherein said metallic compound is any of Si_3N_4 , SiO_2 and Al_2O_3 .

5. (Original) The polycrystalline structure film according to claim 1, wherein said metallic nucleation sites include platinum atoms.

6. (Original) The polycrystalline structure film according to claim 1, wherein said metallic nucleation sites contain said compound in a range between 5at% and 20at%.

7-17. (Cancelled)